







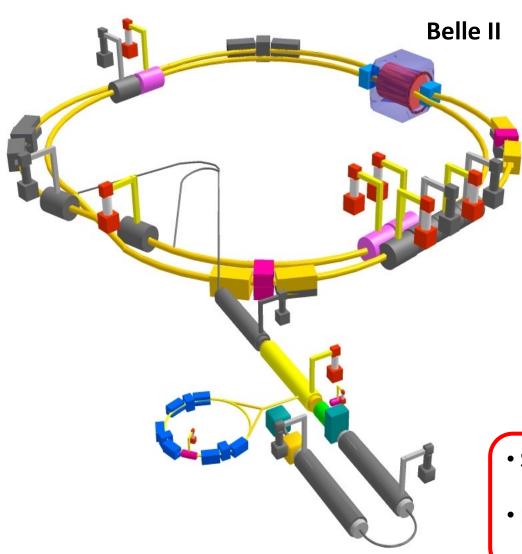


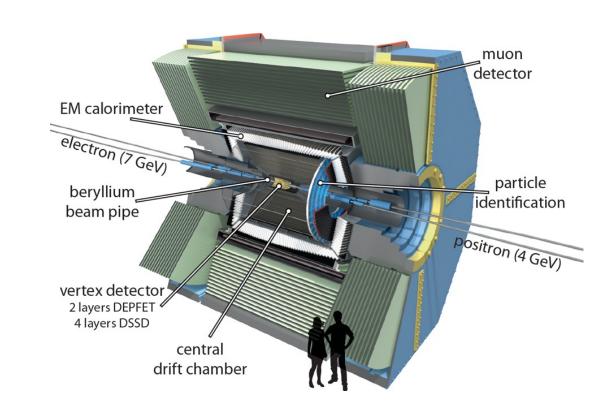
# The DMAPS Upgrade of the Belle II Vertex Detector

C. Marinas, IFIC (CSIC-UV)

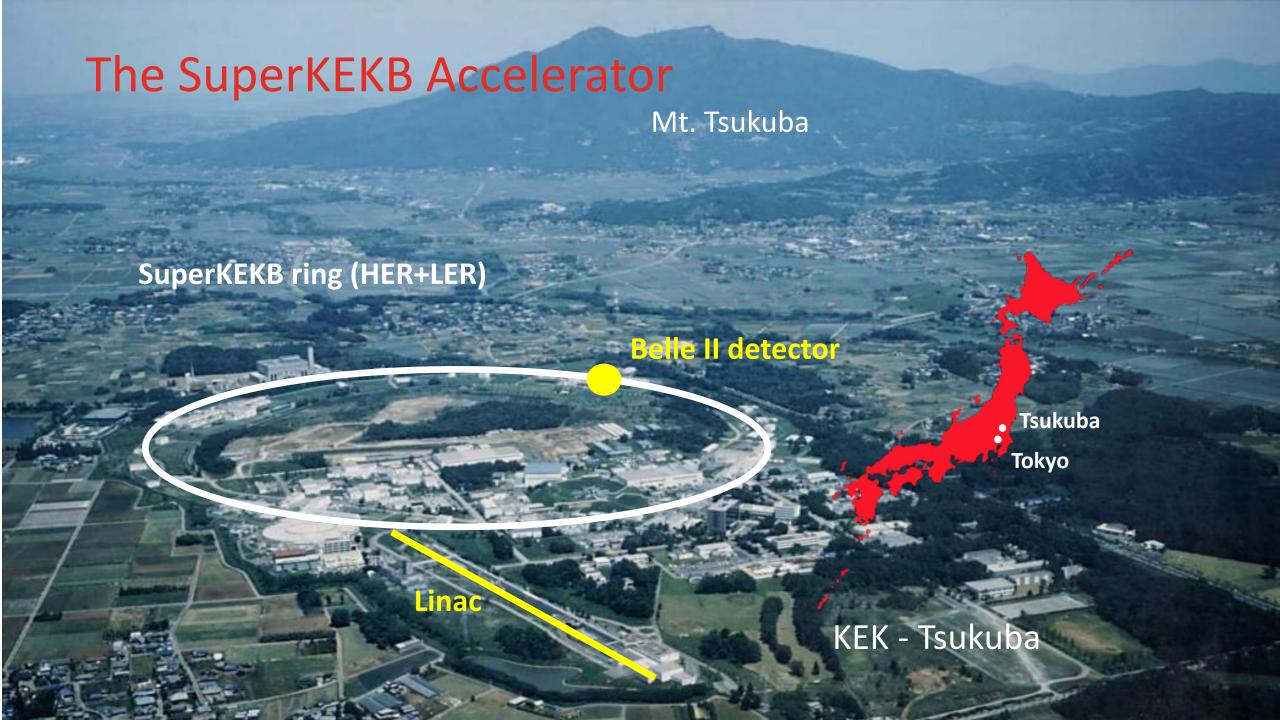


#### SuperKEKB and the Belle II Experiment

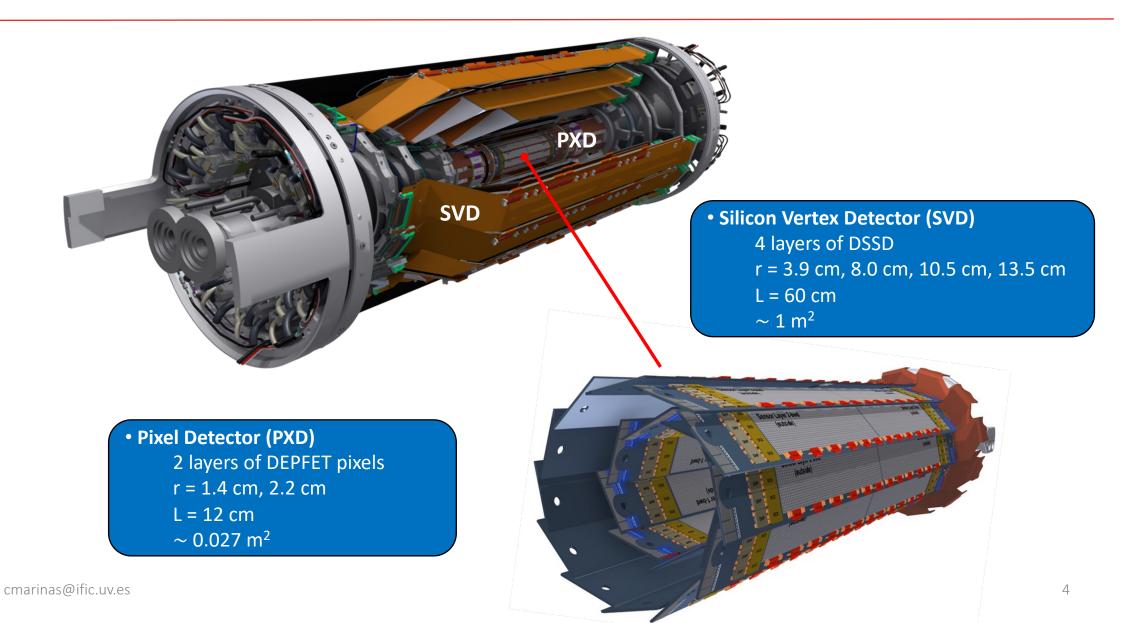




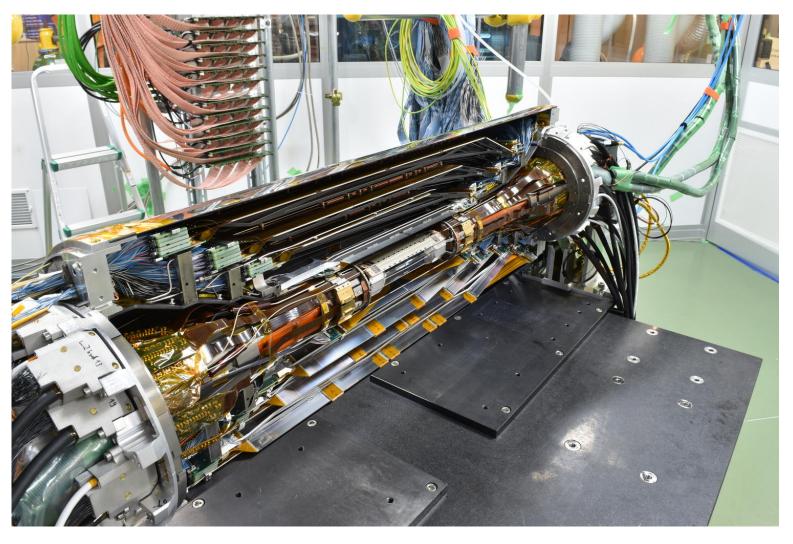
- SuperKEKB: Asymmetric energy  $e^+e^-$  collider  $E_{cm} = m(\Upsilon(4S)) = 10.58 \text{ GeV}$
- Peak luminosity:  $\mathcal{L} = 6.10^{35}$  cm<sup>-2</sup> s<sup>-1</sup> (x30 than KEKB) Beam size reduction. Higher current (x2 higher).



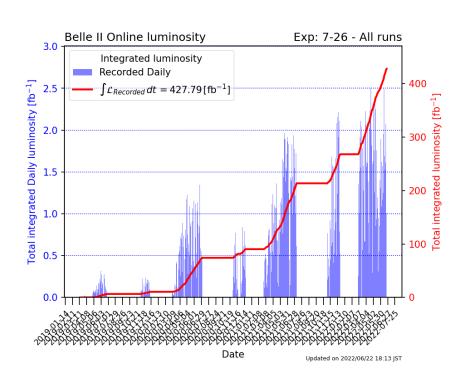
#### Belle II Vertex Detector

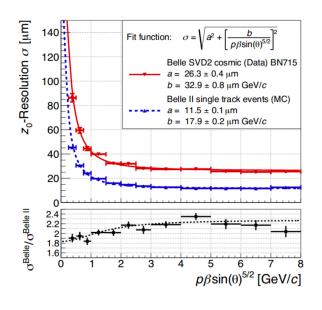


# Belle II VXD during Run 1



#### End Run 1 Status and Performance Benchmarks





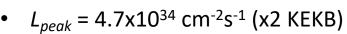
Excellent tracking performance (2x better single vertex resolution wrt Belle)

> World's best D lifetime measurement with only 72 fb<sup>-1</sup>

> > Belle II

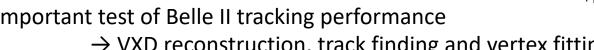
Belle 102

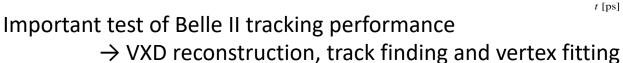
BABAR



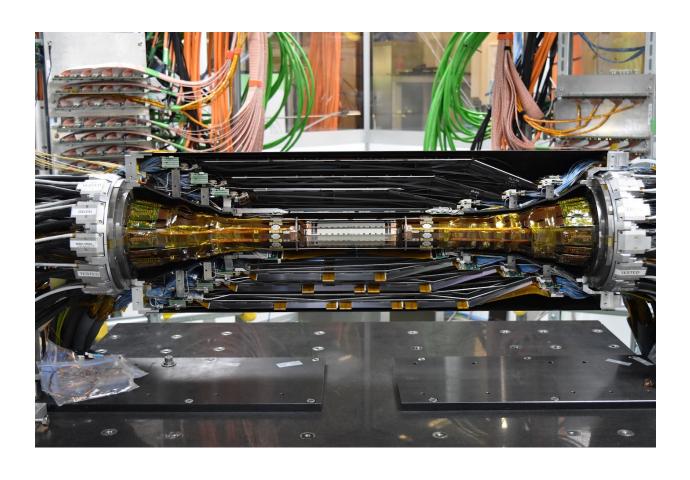
- $L_{\text{integrated}} = 430 \text{ fb}^{-1} (\text{~BaBar})$
- Data taking efficiency ~90%
- **Precision measurements**

Decay time resolution x2 better than Belle and BaBar





# VXD Detector Upgrade – LS1 (2022/2023)



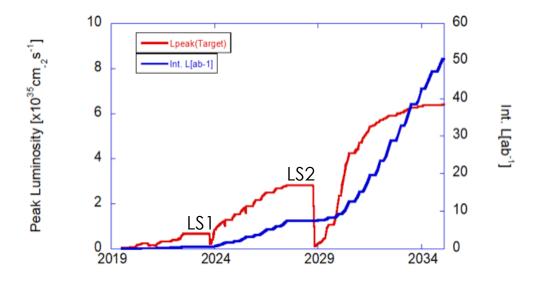
- Detector upgrades:
- Installation of complete pixel detector

- Machine upgrades:
- New more resilient collimators
- Additional background shielding

 $\rightarrow$  Run 2 ongoing. Target for 2024: 10<sup>35</sup> cm<sup>-2</sup>s<sup>-1</sup>

### Belle II Upgrade Program

#### SuperKEKB peak & integrated luminosity vs time



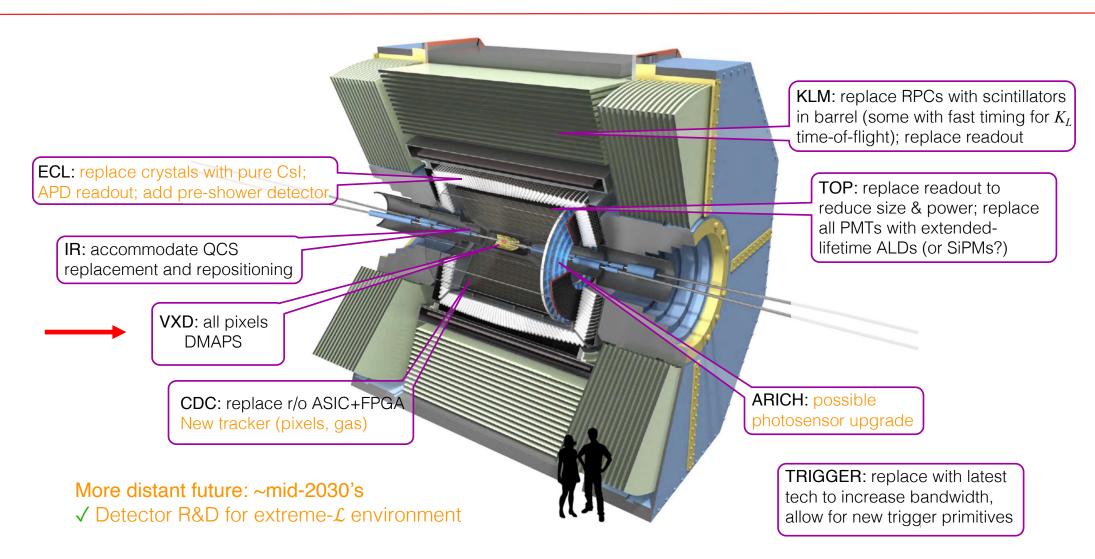
LS1: Actual detector consolidation

LS2: Possible IR and detector upgrades

#### Path to the future:

- 1) Improve machine performance and stability Beam blowup, lifetime, injection power, beam losses
- 2) Reduce detector backgrounds Single beam, injection and luminosity backgrounds
- 3) LS1 Detector consolidation toward 2x10<sup>35</sup> cm<sup>-2</sup>s<sup>-1</sup> Installation of more robust components
- 4) LS2 Detector upgrade toward 6x10<sup>35</sup> cm<sup>-2</sup>s<sup>-1</sup> Including possibly a redesign of the interaction region
- → More performant detector and robust against machine-induced backgrounds

# Belle II Upgrades – LS2 and Beyond



#### Requirements for VXD Upgrade

#### Upgrade motivation:

- Cope with larger background activity
- Improve momentum and impact parameter resolution in low p<sub>T</sub> region
- Simplify tracking chain with all layers involved
- Operation without special modes nor data reduction

#### **Key sensor specifications:**

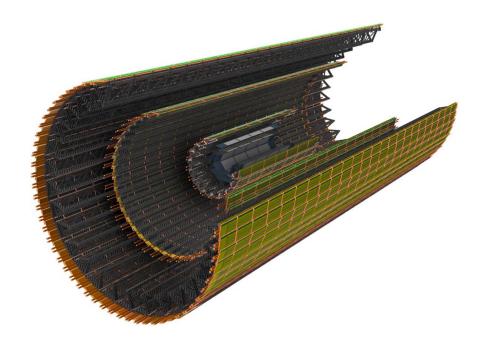
- Pixel pitch 30-40 μm
- Integration time ≤100 ns
- Power dissipation  $\lesssim 200 \text{ mW/cm}^2$

#### Improve physics reach per ab-1

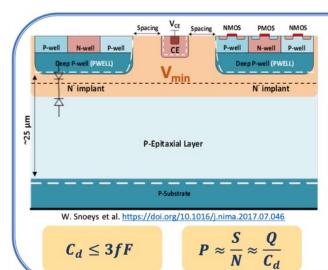
| Radius range  | 14 – 135 mm   |  |  |
|---|---|--|--|
| Tracking & Vertexing performance                                |   |  |  |
| Single point resolution   | < 15 μm   |  |  |
| Material budget   | 0.2% X <sub>o</sub> / 0.7% X <sub>o</sub> inner- / outer- layer |  |  |
| Robustness against high radiation environment (innermost layer) |   |  |  |
| Hit rate  | ~ 120 MHz/cm <sup>2</sup>                                       |  |  |
| Total ionizing dose   | ~ 10 Mrad/year  |  |  |
| NIEL fluence  | ~ 5e13 n <sub>eq</sub> /cm²/year                                |  |  |

## Belle II Upgrade: VTX - DMAPS

- 5 straight layers barrel, using CMOS pixel sensors
- Low material :  $0.2\% X_0 (L1+L2) 0.5\% (L3) 0.8\% X_0 (L4+L5)$
- Moderate pixel pitch ~ 30 μm²
- Time precision 50-100 ns
  - Option for track-triggering with a fast low-space-granularity
- iVTX: innermost 2 layers, self-supported, air cooled
- oVTX: 3 outer layers, CF structure, water cooled
- Overall service reduction and operation simplification



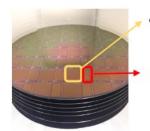
### **TJ-Monopix Family**



#### DMAPS in TJ 180 nm: Concept

- Small sensor capacitance (Cd)
  - · Key for low power/low noise
- Radiation tolerance challenges
  - Modified process
  - Small pixel size
- Design challenges
  - Compact, low power FE
  - Compact, efficient R/O

#### Large scale demonstrator chip development



- MALTA
  - Asynchronous readout
- TJ-Monopix1
  - Synchronous column-drain R/O



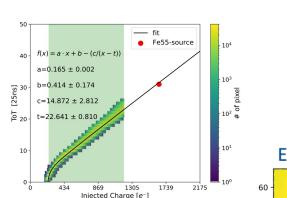
- Process modification enhancements, Cz substrate ⇒ improved efficiency
- TJ-Monopix2: Improved full-scale DMAPS

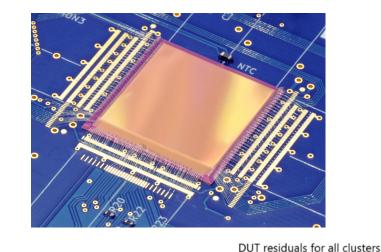


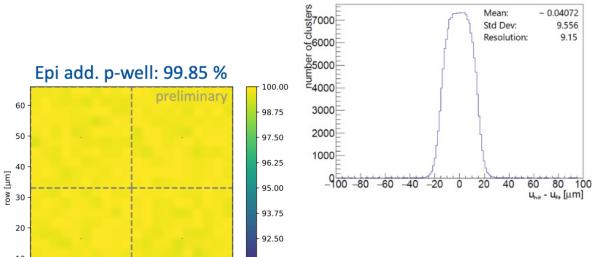
Present

#### TJ-Monopix2 Characterization

- TJ-Monopix2 as forerunner of OBELIX
  - 33x33 μm<sup>2</sup> pitch, 25 ns integration, 2x2 cm<sup>2</sup> matrix
  - 7 bit ToT information, 3 bit in-pixel threshold tuning
  - Various sensing volume thickness (CZ-bulk, epi-30 μm)
- Detailed characterisation
  - In-laboratory
    - Threshold / noise
    - ToT calibration
  - In-beam (DESY, 5 GeV electrons)
    - Efficiency ~99%
    - Position resolution ~9 μm







91.25

column [µm]

### Irradiated TJ-Monopix2 Test Beam

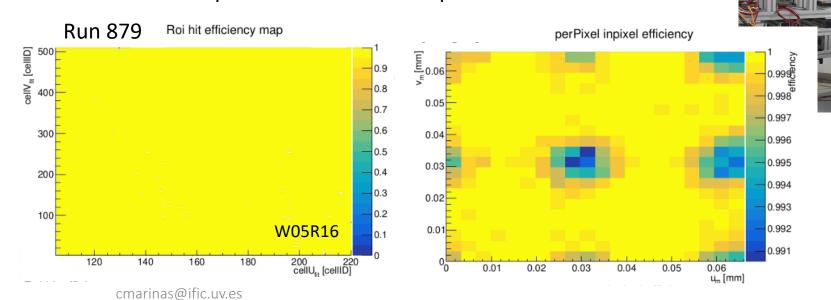
| Serial | Irradiation                   | Substrate |
|--------|-------------------------------|-----------|
| W02R05 | None                          | 30 μm EPI |
| W02R09 | Neutrons 1 × 10 <sup>14</sup> | 30 μm EPI |
| W05R16 | Protons 5 × 10 <sup>14</sup>  | 30 μm EPI |
| W08R19 | None                          | 30 μm EPI |
| W14R12 | None                          | Cz        |

Parameter scans:

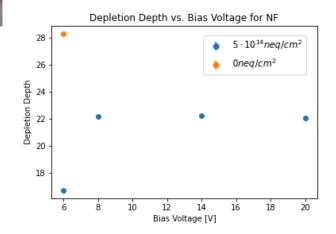
HV, IBias, PSub, VClip, BCID, ...

Angular scans, resolution, efficiency

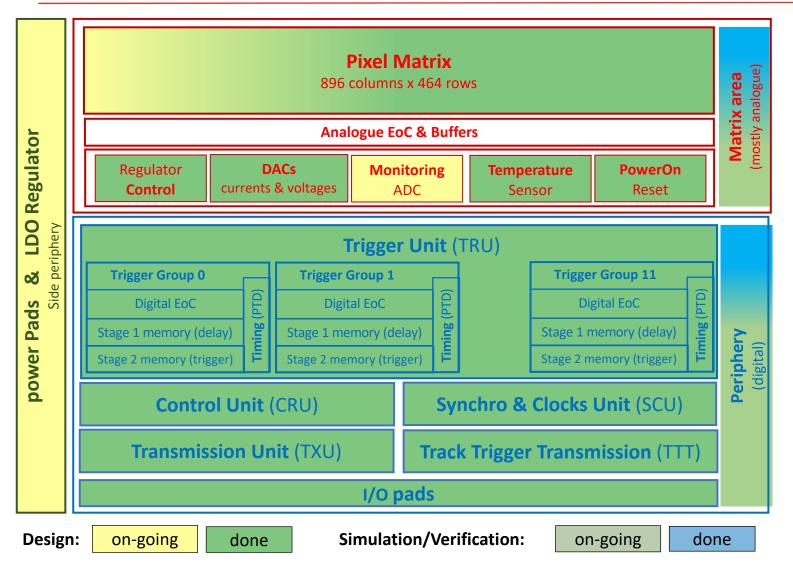
Efficiency >99% for  $5x10^{14}$   $n_{eq}/cm^2$  (310  $e^-$  threshold) Cluster position residuals ~9.5  $\mu m$ 



Telescope planes 4-6 TJ-Monopix2



#### OBELIX – Design Status

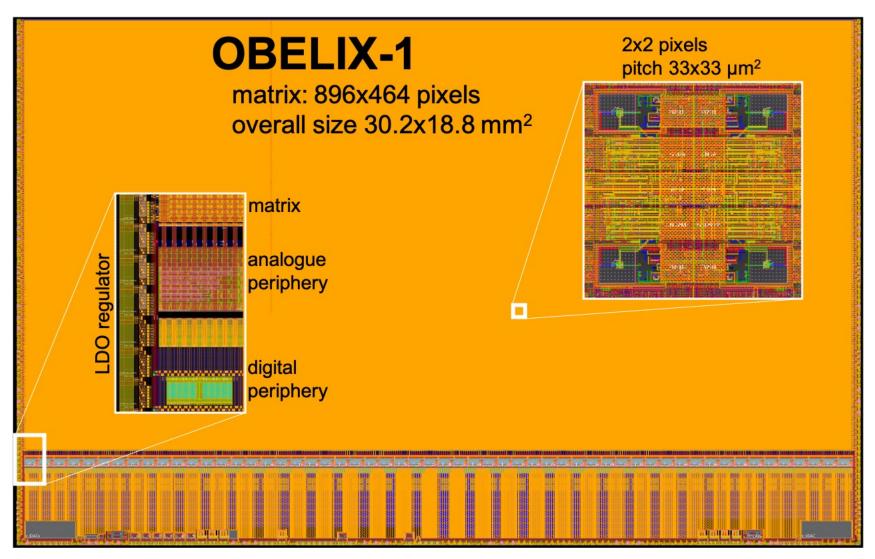


- Main functionalities done (but regulator)
  - Pixel options chosen
- Final integration on-going
- Simulation/verification = main activity
- Documentation: started



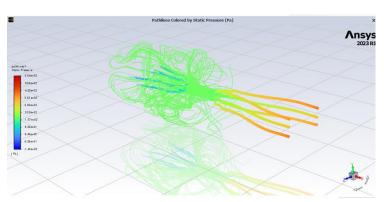
Submission: Q3-2024

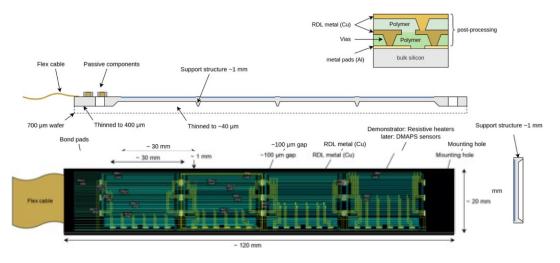
### OBELIX – Layout

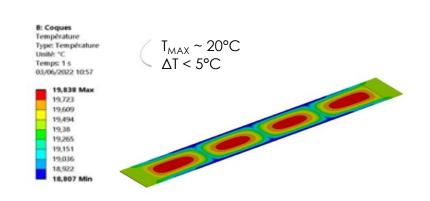


### iVTX Inner Layer Concept

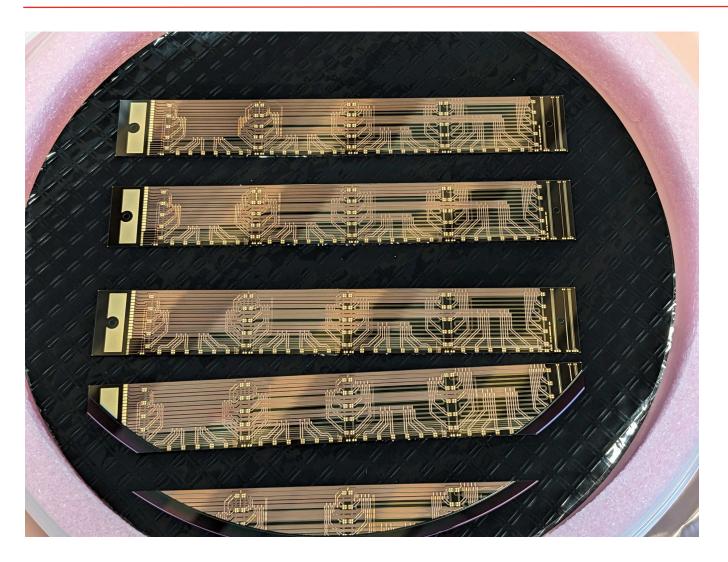
- All-silicon module < 0.15 % X<sub>0</sub>
  - 4 contiguous sensors diced as a block from the wafer
  - Redistribution layer for interconnection
  - Heterogeneous thinning for thinness & stiffness
- Prototyping
  - First real-size ladders at IZM-Berlin with dummy Si
    - True iVTX geometry available
- Simulation on cooling
  - Dry air cooling 15°C
  - Assume 200 mW/cm<sup>2</sup>







#### iVTX Ladder Demonstrator



• Production finished smoothly:

FE-I3 and heaters 300 – 700 um thick

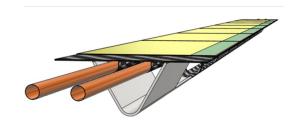
Characterization started:

First quality inspection with needles shows resistivity is on the expected range.

Integrity of data lanes will follow

#### oVTX Outer Layer Concept

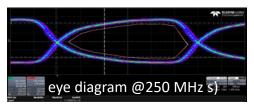
- Long ladders
  - Evolving from ALICE-ITS2
    - Carbon-fiber truss support frame
    - Cold-plate with water coolant
    - Long-flex for power & data



- L3-4, radius 4-9 cm, length < 50 cm
  - Single sensor row, ~0.5 % X<sub>0</sub>
- L5, radius 14 cm, length 70 cm
  - Double sensor rows,  $\sim 0.8 \% X_0$

- Prototypes for L5 under test
  - Deformation & vibration
    - Max sagitta ~500 μm
    - First resonance f=250 Hz
  - Signal propagation
  - Cooling at T<sub>room</sub> ~24°C
    - Leakless water flow at T<sub>in</sub> = 10°C
    - Heaters dissipating 200 mW/cm<sup>2</sup>
    - 22°C < T<sub>sensors</sub> < 26°C







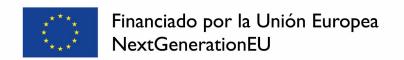


### Summary: LS2 Upgrade Plans

- <u>Vertex detector</u>: Plans to replace VXD with a fully pixelated CMOS detector (VTX)
  - TJ-Monopix2 performance, including irradiated devices, matches expectations
    - → Solid steppingstone towards OBELIX, to be submitted in Q3 2024
  - Preparing complete ladder demonstrators, including its test stands
    - → Detector layer concept validations incorporated on the CDR
  - Preparing the next big step: TDR



# **THANK YOU**







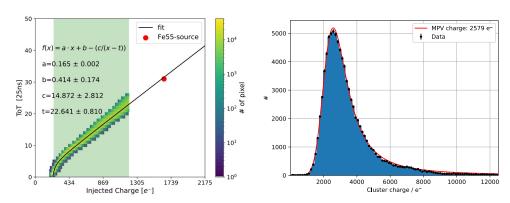


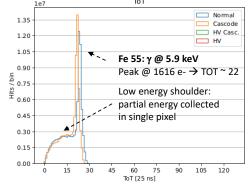
#### TJ-Monopix2 Characterization

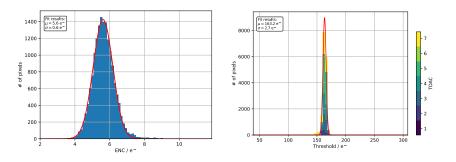
For all FE flavors and all pixels:

Noise, threshold and threshold dispersion

ToT calibration curve (internal injection and sources)







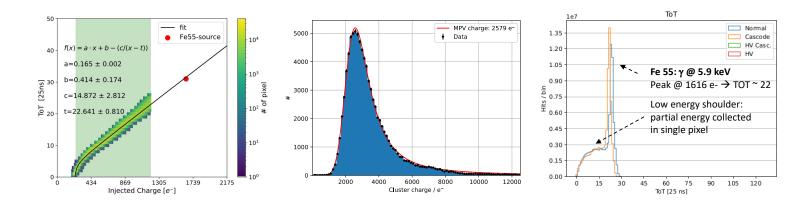
Consistently achieving <300 e<sup>-</sup> threshold levels in all samples

### TJ-Monopix2 Characterization

For all FE flavors and all pixels:

Noise, threshold and threshold dispersion

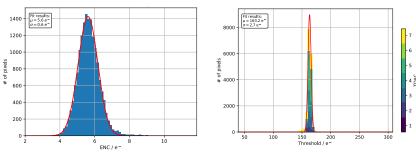
ToT calibration curve (internal injection and sources)



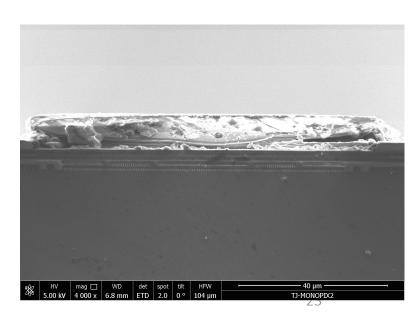
Bonding issues while preparing new samples:

→ Currently ~ 50% success rate

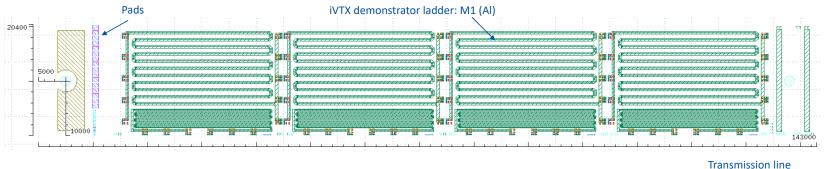
Several samples neutron irradiated up to  $5x10^{14}$   $n_{eq}/cm^2$  available  $\rightarrow$  Characterization ongoing



Consistently achieving <300 e<sup>-</sup> threshold levels in all samples

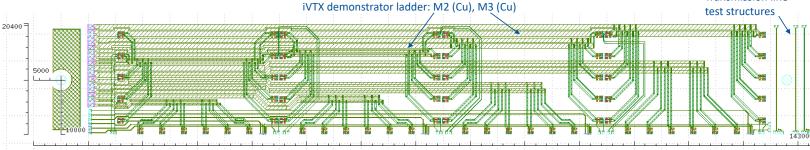


#### iVTX Ladder Demonstrator



#### Metal system:

- Resistive heaters: 1.5 um Al (M1)
- 2 RDL metal layers: 3 um Cu (M2, M3)
- Top metal finish: NiAu (M4)
   Wirebonding, SMD soldering

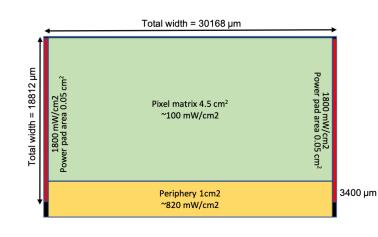


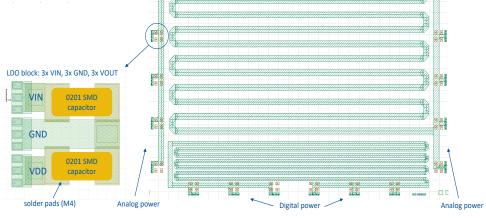
Final ladder dimension: 143 x 20.4 mm<sup>2</sup>

Dummy heaters: 30 x 20 mm<sup>2</sup>

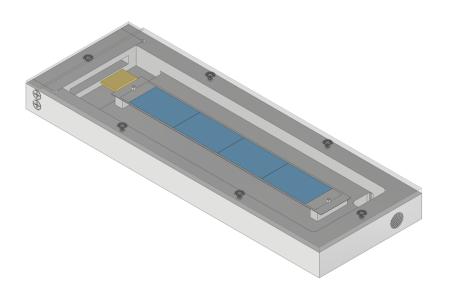
Prepared for 1.7 mm mounting hole

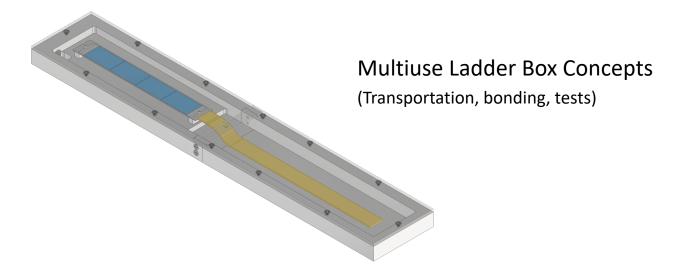
Characterization electrical, mechanical and thermal performances of iVTX ladders

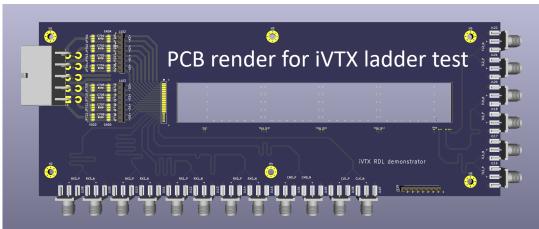




#### **iVTX Ladder Tests**





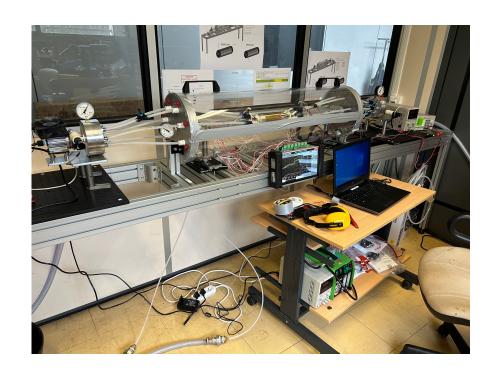


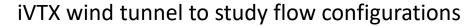
Configurable power routing and test points for I\*R drop measurements

SMA connection for data lanes and and TDR measurements

Also preparing a PCB mockup of the ladder to practice soldering etc

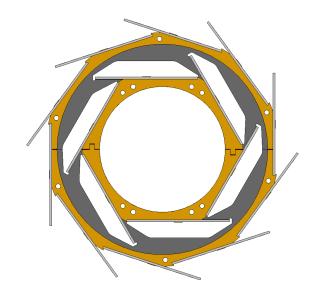
# iVTX Integration and Cooling

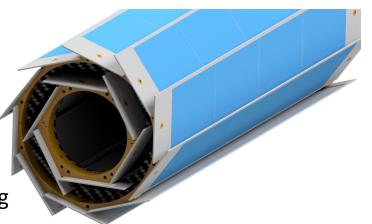


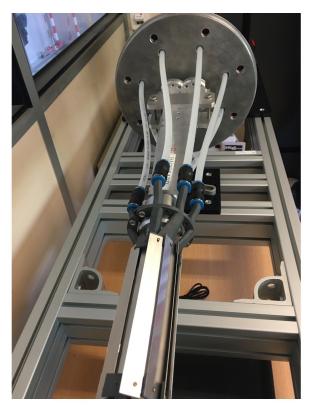


Air cooling feasibility still under study

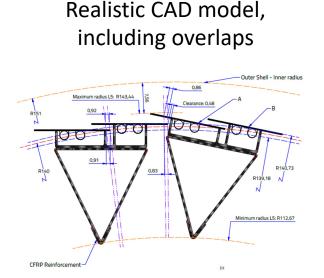
First ideas on ladder mounting and service routing

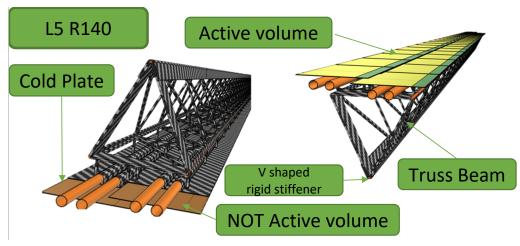


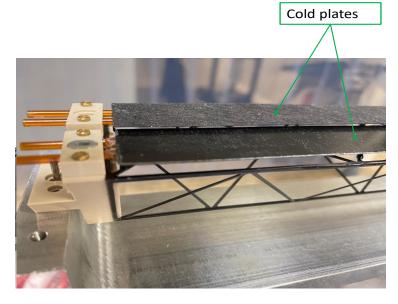




### **oVTX Stave Integration**







Studying thermomechanical properties with realistic models Designing effort on production jigs and assembly procedures Ladder concept compatible with  $X/X_0$  expectations (0.4-0.8%)

| 2 flex from FW and BW side (6 + 6 chip<br>12 chips |          |  |
|--|----------|--|
| COMPONENT  | X/X0 (%) |  |
| Support Structure                                  | 0,087%   |  |
| Cold Plate   | 0,064%   |  |
| Pipes & Coolant                                    | 0,048%   |  |
| Glue   | 0,022%   |  |
| Flex (FW + BW)                                     | 0,150%   |  |
| Chips  | 0,066%   |  |

| Layer 4 R89 Radiation length summary<br>2 flex FW and BW side (8 + 8 chips) - 16<br>chips |          |  |
|---|----------|--|
| COMPONENT   | X/X0 (%) |  |
| Support Structure   | 0,086%   |  |
| Cold Plate  | 0,069%   |  |
| Pipes & Coolant   | 0,048%   |  |
| Glue  | 0,021%   |  |
| Flex FW + BW  | 0,161%   |  |
| Chips   | 0,067%   |  |
|   |          |  |
| Grand Total   | 0,454%   |  |

| Layer 5 R140 Radiation length summary<br>2 flex FW and BW side (12 + 12 chips) - 24<br>chips |          |  |  |
|--|----------|--|--|
| COMPONENT  | X/X0 (%) |  |  |
| Support Structure  | 0,169%   |  |  |
| Cold Plate   | 0,093%   |  |  |
| Pipes & Coolant  | 0,153%   |  |  |
| Glue   | 0,127%   |  |  |
| Flex FW + BW   | 0,186%   |  |  |
| Chips  | 0,069%   |  |  |
|  |          |  |  |
| Grand Total  | 0,796%   |  |  |